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PATENT ABSTRACTS OF JAPAN

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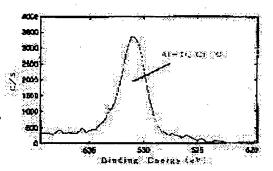
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(54) HARD COATING

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a hard coating, improving the high-temperature oxidation resisting characteristic, adhesion, and wear resistance of (AICr)N series coating, and having high hardness.

SOLUTION: This hard coating is formed by arc discharge ion plating method. The hard coating is represented by (AlxCrl-x-y-zSiyMz) (N1- α - β - γ B α C β O γ). The hard coating has a diffraction strength on rock salt structure type (200) face by X-ray diffraction, half-power band width thereof is from 0.5° to 2.0° both inclusive, and the hard coating has binding energy of at least Al, Cr, M and/or Si and oxygen in the region of 525eV to 535eV in X-ray photoelectron spectral analysis. The reference signs, x, y, z, α , β , γ respectively designate atomic percentage. 0.45<x<0.85, 0<y<0.35, 0.50<x+y+z<1.0, 0<z<0.20, 0<\alpha<0.15, 0<\bega<0.65, 0<\ga<0.65, 0<\alpha+\gamma<1.0, and M is selected from one or two or more kinds of elements among Ca, Mn, Sr, Y, Zr, Ce, Nd, Sm, Tb, Dy, Er and Yb.



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